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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.	
10/078,720	02/19/2002	Kaidong Ye	4795-004	5412	
24112 7	2590 07/11/2003				
COATS & BENNETT, PLLC			EXAMINER		
P O BOX 5 RALEIGH, NO			ELVE, MARIA	ELVE, MARIA ALEXANDRA	
			ART UNIT	PAPER NUMBER	
			1725		

DATE MAILED: 07/11/2003

Please find below and/or attached an Office communication concerning this application or proceeding.

•	.		m
		Application No.	Applicant(s)
	_	10/078,720	YE ET AL.
Office Action Summary		Examiner	Art Unit
		M. Alexandra Elve	1725
Period fo	- The MAILING DATE of this communication ap	pp ars on the cover sheet with th	correspondence address
THE N - Exten after S - If the - If NO - Failur - Any f	ORTENED STATUTORY PERIOD FOR REP MAILING DATE OF THIS COMMUNICATION is ions of time may be available under the provisions of 37 CFR 1 SIX (6) MONTHS from the mailing date of this communication. period for reply specified above is less than thirty (30) days, a reperiod for reply is specified above, the maximum statutory perior to reply within the set or extended period for reply will, by statutely received by the Office later than three months after the mailed patent term adjustment. See 37 CFR 1.704(b).	136(a). In no event, however, may a reply be to the statutory minimum of thirty (30) do do will apply and will expire SIX (6) MONTHS from the cause the application to become ABANDON	imely filed ays will be considered timely. m the mailing date of this communication. IED (35 U.S.C. § 133).
1)	Responsive to communication(s) filed on	·	
2a)	71110 4011017 10 11 11 11 11	This action is non-final.	
3)	Since this application is in condition for allocolosed in accordance with the practice under	wance except for formal matters, er <i>Ex parte Quayle</i> , 1935 C.D. 11,	prosecution as to the merits is , 453 O.G. 213.
=	on of Claims		
-	Claim(s) 1-16 is/are pending in the applicati		
	4a) Of the above claim(s) is/are withd	rawn from consideration.	
5)⊠	Claim(s) <u>1-8</u> is/are allowed.		
6)⊠	Claim(s) <u>9-16</u> is/are rejected.		
-	Claim(s) is/are objected to.		
	Claim(s) are subject to restriction and	d/or election requirement.	
• •	ion Papers		
	The specification is objected to by the Exami		
10)	The drawing(s) filed on is/are: a) ac	cepted or b) objected to by the Ex	caminer.
	Applicant may not request that any objection to	the drawing(s) be held in abeyance.	orough by the Evaminer
11)	The proposed drawing correction filed on		Stoved by the Examiner.
_	If approved, corrected drawings are required in		
,	The oath or declaration is objected to by the	Examiner.	
	under 35 U.S.C. §§ 119 and 120		2(-) (-) (5)
	Acknowledgment is made of a claim for fore	eign priority under 35 U.S.C. § 118	9(a)-(d) or (i).
a)	⊠ All b)□ Some * c)□ None of:		
	1.⊠ Certified copies of the priority docume		
	2. Certified copies of the priority docume		
*	3. Copies of the certified copies of the papplication from the International See the attached detailed Office action for a	Bureau (PCT Rule 17.2(a)).	
	Acknowledgment is made of a claim for dome		
	a)	provisional application has been	received.
Attachme			
1) 🔀 Not	nt(s) ice of References Cited (PTO-892) ice of Draftsperson's Patent Drawing Review (PTO-948) rmation Disclosure Statement(s) (PTO-1449) Paper No(5) Notice of Inform	nary (PTO-413) Paper No(s) nal Patent Application (PTO-152)

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DETAILED ACTION

Claim Rejections - 35 USC § 103

The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:

A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.

Claims 9-10 & 16 are rejected under 35 U.S.C. 103(a) as being unpatentable over Heikilla et al. (US Pat. 6,140,606).

Heikilla et al. discloses a laser cutting system having a laser cutting head and a frame which allows the work to be accessed from three different directions. The laser cutting system has a telescopic system that maintains the parameters of the laser beam using auto focusing, and yields optimum cuts. A linear drive is used to move the laser cutting head along various directions such that the workpiece is effectively fabricated. The focus of the laser beam for the different areas of the workpiece may be adjusted by moving the laser cutting head bi-directionally along its vertical axis to maintain respective optimal focal points for workpieces of different materials. Another improvement of the cutting head is the provision of a servomechanism, via feedback, for automatically adjusting the focus lens inside the cutting head. The movement of the cutting head and the laser beam direction are controlled by a CNC. Additionally, a CNC controller may be used to make corrections.

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Heikilla discloses autofocussing and a telescopic system, but does not specifically teach refocusing or vertical movement. It would have been obvious to one of ordinary skill in the art at the time of the invention to realize that a telescopic system involves linear movement towards or away from a workpiece and in this case the movement would be in the vertical direction towards and away from the workpiece. Additionally, autofocussing is inherently a refocusing mechanism and thus is taught by the prior art.

Heikilla does not teach a workpiece which is an integrated circuit. Intended use has been continuously held not to be germane to determining the patentability of the apparatus, In re Finsterwalder 168 USPQ 530.

Claims 11-13 are rejected under 35 U.S.C. 103(a) as being unpatentable over Heikilla, as stated in the rejection of claims 9-10 & 16, above and further in view of Manor (US 2001/0035401).

Heikilla discloses the use of a laser for cutting workpieces although the exact wavelengths are not taught.

Manor teaches the use of first and second laser beams in order to cut/scribe lines on a workpiece; a semiconductor wafer. Lasers include UV, CO2, Nd:YAG and so forth. Wavelengths range from 193 nm to 532 nm. It would have been obvious to one of ordinary skill in the art at the time of the invention to use lasers of different wavelengths are as taught by Manor in the Heikilla apparatus because these are merely different varieties of lasers.

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Claims 14-15 are rejected under 35 U.S.C. 103(a) as being unpatentable over Heikilla, as stated in the rejection of claims 9-10 & 16, above and further in view of Matsumoto et al. (US Pat. 6,498,319).

Heikilla discloses laser cutting but does not teach a fluid flow in the workpiece region.

Matsumo teaches the cutting of sheets for electronic circuit boards. Multiple layers are cut using a laser. The cutting nozzle has a gas attachment, which is used to blow cutting powder and residual away from the workpiece. It would have been obvious to one of ordinary skill in the art at the time of the invention to use gas for blow or cleaning debris, as taught by Matsumo in the Heikilla apparatus because this results in a more precise cut.

Allowable Subject Matter

Claims 1-8 are allowed.

The following is a statement of reasons for the indication of allowable subject matter: the claims as supported by the specification differs from the prior art in that it does not teach a method for cutting a substrate in which a laser beam is focused and laterally moved to follow a path, removing a first layer, in order to reveal a second layer

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and then the beam is refocused and moved along the same path cutting the second material layer.

Conclusion

The prior art made of record and not relied upon is considered pertinent to applicant's disclosure. See US PTO-892.

Any inquiry concerning this communication or earlier communications from the examiner should be directed to M. Alexandra Elve whose telephone number is 703-308-0092. The examiner can normally be reached on 6:30-3:00 Monday to Friday.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Tom Dunn can be reached on 703-308-2383. The fax phone numbers for the organization where this application or proceeding is assigned are 703-305-3599 for regular communications and 703-305-3599 for After Final communications.

Any inquiry of a general nature or relating to the status of this application or proceeding should be directed to the receptionist whose telephone number is 703-308-0661.

July 9, 2003.

M. ALEXANDRA ELVE PRIMARY EXAMINER